

AMENDMENTS TO THE SPECIFICATION

Please amend full paragraph 2, with the following amended paragraph:

Please referring to figure 6B, the posts 512 are defined by patterning the material layer 510 during a photolithographic process. The post 512 has a support 514 disposed in the opening 508, and the post 512 has arms 5121 and 5122. The same photolithographic process also defines the lengths of arms 5121 and 5122. The thicknesses of the arms 5121 and 5122 are decided in the step of forming the material layer 510. A second electrode ~~504~~ 540 is formed on the sacrificial layer 506 and the post 512.